

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

PRECISION POLYSILICON RESISTOR PROCESS

Application Number :

Confirmation Number:

First Named Applicant: Douglas Coolbaugh

Attorney Docket Number: BUR920020094US1

Art Unit:

Examiner:

Search string: (4256515 or 4502894 or 4604789 or 4679170 or 4929570 or 5506158 or 5554554 or 5585302 or 6184103 or 6249029 or 6255185 or 6399456 or 6400252).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
LV	1	4256515	1981-03-17	Miles et al			
	2	4502894	1985-03-05	Seto et al			
	3	4604789	1986-08-12	Bourassa			
	4	4679170	1987-07-07	Bourassa et al.			
	5	4929570	1990-05-29	Howell			
	6	5506158	1996-04-09	Eklund			
	7	5554554	1996-09-10	Bastani et al.			
	8	5585302	1996-12-17	Li			
	9	6184103	2001-02-06	Li et al.			
	10	6249029	2001-06-19	Bryant et al.			
	11	6255185	2001-07-03	Collbaugh et al.			
	12	6399456	2002-06-04	Huang et al.			
LV	13	6400252	2002-06-04	Smith et al.			

Signature

Examiner Name	Date
LAN VINH	5/1/05